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标题: Mapping inter-element coupling in metamaterials: Scaling down to infrared

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摘要: The coupling between arbitrarily positioned and oriented split ring resonators is investigated up to THz frequencies. Two different analytical approaches are used, one based on circuits and the other on field quantities that includes retardation. These are supplemented by numerical simulations and experiments in the GHz range, and by simulations in the THz range. The field approach makes it possible to determine separately the electric and magnetic coupling coefficients which, depending on orientation, may reinforce or may cancel each other. Maps of coupling are produced for arbitrary orientations of two co-planar split rings resonant at around 2 GHz and then with the geometry scaled down to be resonant at around 100 THz. We prove that the inertia of electrons at high frequencies results in a dramatic change in the maps of coupling, due to reduction of the magnetic contribution. Our approach could facilitate the design of metamaterials in a wide frequency range up to the saturation of the resonant frequency. (C) 2012 American Institute of Physics. [http://dx.doi.org/10.1063/1.4711092]

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